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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/604,835	08/21/2003	Hung-Wei Liu	11437-US-PA	1834
31561 75	590 06/15/2004		EXAMINER	
JIANQ CHYUN INTELLECTUAL PROPERTY OFFICE			VU, QUANG D	
	7 FLOOR-1, NO. 100 ROOSEVELT ROAD, SECTION 2		ART UNIT	PAPER NUMBER
TAIPEI, 100	•	,o==0:.=	2811	
TAIWAN			DATE MAILED: 06/15/200	4

Please find below and/or attached an Office communication concerning this application or proceeding.

			9m
	Application No.	Applicant(s)	
	10/604,835	LIU ET AL.	
Office Action Summary	Examiner	Art Unit	
	Quang D Vu	2811	
The MAILING DATE of this communication ap Period for Reply	pears on the cover sheet with th	e correspondence ad	ddress
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a replication of the period for reply is specified above, the maximum statutory period. - Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply be only within the statutory minimum of thirty (30) I will apply and will expire SIX (6) MONTHS fite, cause the application to become ABANDO	e timely filed days will be considered time rom the mailing date of this of DNED (35 U.S.C. § 133).	ly. communication.
Status			
1) Responsive to communication(s) filed on	·		
· _ ·	s action is non-final.		
3) Since this application is in condition for allows	•	•	e merits is
closed in accordance with the practice under	Ex parte Quayle, 1935 C.D. 11,	453 O.G. 213.	•
Disposition of Claims			
4) Claim(s) 1-14 is/are pending in the application 4a) Of the above claim(s) is/are withdra 5) Claim(s) is/are allowed. 6) Claim(s) is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) 1-14 are subject to restriction and/or	awn from consideration.		
Application Papers			
9) The specification is objected to by the Examin 10) The drawing(s) filed on is/are: a) acc Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the E	cepted or b) objected to by the drawing(s) be held in abeyance. ction is required if the drawing(s) is	See 37 CFR 1.85(a). objected to. See 37 C	
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Bureat * See the attached detailed Office action for a list	nts have been received. Its have been received in Application of the second in Application of the seco	cation No eived in this National	Stage
Attachment(s)	4) 🖂 Interview Summer	on/(PTO 412)	
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08 Paper No(s)/Mail Date 	4)		O-152)

Election/Restrictions

DETAILED ACTION

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- I. Claims 1-10, drawn to a method for forming a metal silicide layer, classified in class 438, subclass 682.
- II. Claims 11-14, drawn to a metal silicide structure, classified in class 257, subclass388.

The inventions are distinct, each from the other because of the following reasons:

Inventions I and II are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case the device of group II invention could be made by a materially different process. For example, insitu doped silicon layer can be provided, instead of providing a silicon layer and introducing ions in the silicon layer.

Because these inventions are distinct for the reasons give above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Quang D Vu whose telephone number is 571-272-1667. The examiner can normally be reached on Monday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie Lee can be reached on 571-272-1732. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

qv June 2, 2004

> EDDIE LEE SUPERVISORY PATENT EXAMINER

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